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Anisotropic magnetoresistance in  $\mathbf{Sr}_{2}\mathbf{IrO}_{4}^{1}$  C. WANG, H. SEINIGE, University of Texas at Austin, G. CAO, University of Kentucky, J.-S. ZHOU, J.B. GOODENOUGH, M. TSOI, University of Texas at Austin — We report the first measurements of the point-contact magnetoresistance (MR) of antiferromagnetic semiconductor  $Sr_2IrO_4$ . The point-contact technique allows to probe very small volumes associated with point contacts and, therefore, looks for electronic transport on a microscopic scale. Point-contact measurements with single crystals of  $Sr_2IrO_4$ were intended to see if the additional local resistance associated with a small contact area between a sharpened Cu tip and the antiferromagnet shows MR such as that seen in bulk crystals. The  $Sr_2IrO_4$  crystals were grown by the flux method. Pointcontact measurements at liquid nitrogen temperature revealed large MRs (up to 8%) for modest magnetic fields (250 mT) applied within  $IrO_2$  (ab) plane. The angular dependence of MR shows a crossover from four-fold to two-fold symmetry with an increasing magnetic field which may be tentatively attributed to the field-induced changes of antiferromagnetic order within IrO<sub>2</sub> planes. The observed MR can be potentially used to sense the antiferromagnetic order in spintronic applications.

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